Interfacial Defect Passivation and Charge Carrier Management for Efficient Perovskite Solar Cells via Highly Crystalline Polymer

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Experimental Section

Materials.

Fluorine doped tin oxide (FTO) coated glass substrates, TiO₂ paste, Acetylacetone, Titanium diisoproxide bis(acetylacetonate) 75% in Isopropyl Alcohol, N, N'dimethylformamide (DMF), dimethyl sulfoxide (DMSO), 4-tert-butylpyridine (tBP), bis(trifluoromethylsulfonyl)imide lithium salt (LiTFSI), Tris(2-(1Hpyrazol-1-yl)-4tert-butylpyridine)-cobalt(III) tris(bis(trifluoromethyl- sulfonyl) imide) (FK 209), chlorobenzene (CB). acetonitrile (ACN), 2,7-dioctyl[1]benzothieno[3,2 $b][1] benzothiophene \ (C8-BTBT), were purchased from \ Sigma-aldrich. \ N^2, N^2, N^{2'}, N$ N⁷, N⁷, N⁷'-octakis(4-methoxyphenyl)-9, 9'-spirobi[9H-fluorene]-2, 2', 7, 7'tetramine (Spiro-OMeTAD), Cesium iodide (CsI), formamidiniumiodide (FAI), and methylammonium bromide (MABr) were supplied from greatcell. Lead iodide (PbI₂) and lead bromide (PbBr₂) were purchased from TCI Chemicals. All materials were used as received without further purification.

Film and device Fabrication.

Laser patterned FTO substrates (7 Ω per square) were ultrasonically cleaned with running water, detergent, ethanol, and acetone for 20 min in sequence. After drying, a compact TiO₂ layer was deposited on the cleaned FTO glass by spray pyrolysis from a precursor solution of 0.6 mL titanium diisopropoxide bis(acetylacetonate) and 0.4 mL acetylacetonate in 9 mL anhydrous ethanol. After sintering, a mesoporous TiO₂ layer was spin-coated onto the TiO₂ compact layer at 5000 rpm for 20 s, and sintered again. Then, all substrates were transferred to a nitrogen-filled glovebox for perovskite deposition. (FAPbI₃)_{0.875}(MAPbBr₃)_{0.075}(CsPbI₃)_{0.05}(PbI₂)_{0.03} perovskite precursor solution was prepared by dissolving 1.30 M PbI₂, 1.19 M FAI, 0.14 M PbBr₂, 0.14 M MABr, and 0.07 M CsI into the DMSO/DMF (1/4 v/v) mixture. The perovskite film was deposited by a consecutively spin-coating process at 2000 rpm for 10 s and 6000 rpm for 30 s on the surface of TiO₂ layer. At the time of 15 s prior to the program end, 100 μL of chlorobenzene was dripped on the spinning substrate, and the film was then annealed at 120°C for 1 h. The target devices were obtained by spin-coating different

concentrations (1, 2, 5, 10, 15 40 mg mL⁻¹, dissolved in chlorobenzene) of C8-BTBT polymer at 4500 rpm for 30 s. Subsequently, the Spiro-OMeTAD was spin-coated onto the perovskite/C8-BTBT films at 4500 rpm for 30 s using 69.36 mM of Spiro-OMeTAD in CB with additives of 28.8 μ L t-BP, 17.8 μ L LiTFSI (520 mg mL⁻¹ in ACN), 6.5 μ L FK209 (300 mg mL⁻¹ in ACN). Finally, a gold layer was thermally evaporated under a lower vacuum ($\leq 2 \times 10^{-4}$ Pa) to complete the device fabrication.

Film and device characterizations.

The UV-vis absorption spectra were recorded by a spectrophotometer (UV-2600, Shimadzu). The Normalized differential pulse voltammetry (DPV) was measured by Electrochemical Workstation (Zennium X, Zahner). Current density-voltage characteristics were measured under 100 mW cm⁻² (AM 1.5G illumination) using a Newport solar simulator (model 91160) and a Keithley 2400 source/meter. The external quantum efficiency (EQE) spectra were recorded using a computer-controlled setup consisting of a Xenon light source (Spectral Products ASB-XE-175), a monochromator (Spectra Products CM110), and a potentiostat (LabJack U6 DAQ board), calibrated by a certified reference solar cell (Fraunhofer ISE). The steady-state photoluminescence (PL) measurement was performed using a spectrometer (FLS1000, Edinburgh Instruments). The time-resolved PL (TRPL) decay transients were measured using a picosecond pulse diode laser (EPL-470). Nanosecond transient absorption (TA) spectroscopy was investigated by a spectrometer (LP980, Edinburgh Instruments). The space-charge limited current (SCLC) measurements were performed by collecting the *I–V* characteristics of devices in dark conditions. The surface morphology of films was characterized by scanning electron microscopy (SEM) and atomic force microscope (AFM) with the tapping mode. X-ray diffraction (XRD) patterns of films were measured with a TTR-18KW diffractometer, with Cu K α radiation (λ = 0.15405 nm) operated at 10000 W power (40 kV, 250 mA). X-ray photoelectron spectroscopy (XPS) was performed using a scanning XPS microprobe (K-Alpha+). Femtosecond transient absorption (fs-TA) measurements were performed for the films by using amultipass amplified Ti: sapphire laser (800 nm laser pulses with a 3.5 mJ/pulse; pulse width of ~120 fs with a repetition rate of 2 kHz, Astrella from Coherent; the detection time delay is in the range of 8.5 ns in conjunction with Helios spectrometers. Excitation pump pulses were generated after passing through a fraction of the 800 nm beam into a spectrally tunable (240-2600 nm) optical parametric amplifier (Newport Spectra-Physics). The probe pulses (UV-Visible and NIR wavelength continuum, white light) were generated by passing another fraction of the 800 nm pulses through a 2 mm thick calcium fluoride (CaF2) crystal. All the fs-TA experiments were performed under identical ambient conditions at room temperature. Grazing-incidence wide-angle X-ray scattering (GIWAXS) was performed on a Duo microsourced single-crystal X-ray diffractometer (Bruker D8 Venture) with Photon III detector and Cu-Diamond X-ray sources (λ = 1.5406 Å). The data reduction was processed using APEX3 software. The Fourier-transform infrared spectroscopy (FTIR) spectroscopy was carried out using Nicolet iS10 (Thermo Fisher). The Raman spectroscopy was measured by Confocal Raman Microscope (InVia, Renishaw). A Mettler heating stage (FP 82 HT) was used for polarizing optical microscopy (POM, Optiphot 2, Nikon) and DSC were recorded with a DSC 200 F3 Maia calorimeter (NETZSCH) at 10 K min⁻¹.

SCLC measurement

Hole mobility

Fluorine doped tin oxide (FTO) glass was patterned via laser etching for the fabrication of a hole-only device. The clean FTO glasses were cleaned by ozone treatment again. The PEDOT:PSS layer was spin-coated onto the substrate at 4000 rpm for 30s and annealed at 170°C for 20 min in air. After cooling, the glasses were transferred to the nitrogen-filled glovebox. A film of C8-BTBT, Spiro-OMeTAD and Spiro-C8 was spun at 4500 rpm for 30 s, respectively. The gold layer was finally evaporated density-voltage (*J-V*) curve of a hole-only device was measured with a Keithley 2400 source-measure unit in a nitrogen-filled glovebox.

The hole mobility was derived by fitting J–V curve with Mott-Gurney equation¹:

$$J = \frac{9}{8} \varepsilon_0 \varepsilon_r \mu \frac{V^2}{L^3}$$

where J is the current density. ε_0 is the vacuum permittivity. ε_r is the relative dielectric constant of the material. μ is the hole mobility. L is the thickness of the hole transport layer. V is the applied voltage.

Trap density

The measurement of the trap density (n_{trap}) is the same as the above method with the structure of 1) "hole only" device: FTO/PEDOT:PSS/perovskite/HTM/Au; 2) "electron only" device: FTO/PCBM/perovskite/PCBM/Au. The n_{trap} was estimated using the following equation²:

$$n_{trap} = \frac{2\varepsilon \varepsilon_0 V_{TFL}}{eL^2}$$

where, V_{TFL} is the trap-filled limit (TFL) voltage, ε is the dielectric constant of the perovskite layer. ε_0 is the vacuum permittivity. e is the charge. L is the thickness of the perovskite layer.

TRPL analysis

The TPRL results are fitted through the biexponential equation as below:

$$f(t) = A_1 \exp\left(\frac{-t}{\tau_1}\right) + A_2 \exp\left(\frac{-t}{\tau_2}\right)$$

And the average value of lifetime ($\tau_{ave.}$) is calculated by the following equation:

$$\tau_{ave.} = \frac{A_1 * \tau_1^2 + A_2 * \tau_2^2}{A_1 * \tau_1 + A_2 * \tau_2}$$

 τ_1 and τ_2 represent the fast and slow decay times, which are derived from the charge carriers quenching and the radiative recombination, respectively³⁻⁴.

TA analysis

The TA results are fitted with the biexponential decay function as below:

$$y = A_1 \exp\left(\frac{-t}{\tau_1}\right) + A_2 \exp\left(\frac{-t}{\tau_2}\right) + y_0$$

And the average value of lifetime ($\tau_{ave.}$) is calculated by the following equation:

$$\tau_{ave.} = \frac{A_1 * \tau_1^2 + A_2 * \tau_2^2}{A_1 * \tau_1 + A_2 * \tau_2}$$

 τ_1 and τ_2 represent the fast and slow decay times.⁵

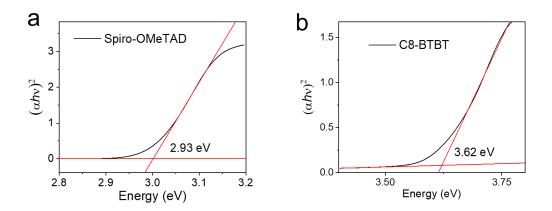


Figure S1. Tauc plots of different solutions in CH₂Cl₂, a) Spiro-OMeTAD and b) C8-BTBT.

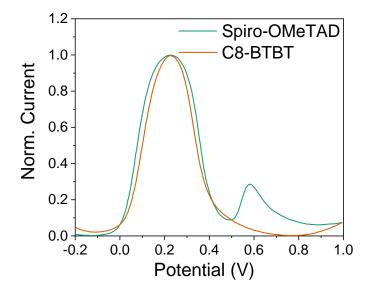


Figure S2. Normalized differential pulse voltammetry (DPV) spectra of Spiro-OMeTAD and C8-BTBT solution in CH₂Cl₂.

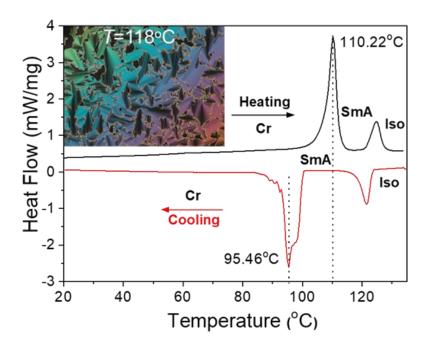


Figure S3. DSC heating and cooling scans (10 K min⁻¹) of bare C8-BTBT powder. Cr = crystalline solid; SmA = Smectic phase; Iso = isotropic liquid state. (Insert: POM textures of smectic liquid crystal under the cross polarizer).

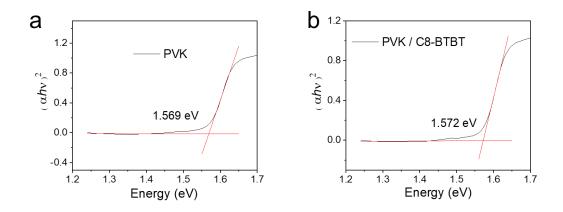


Figure S4. Tauc plots of a) perovskite film and b) perovskite/C8-BTBT film.

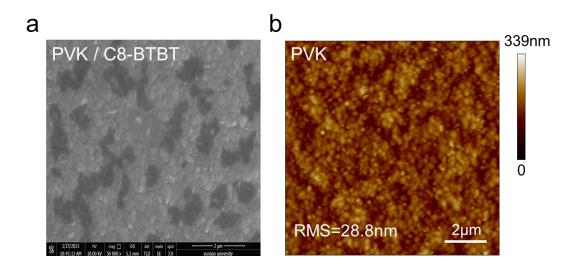


Figure S5. a) The SEM image of C8-BTBT on the surface of perovskite film, b) AFM image of bare perovskite film.

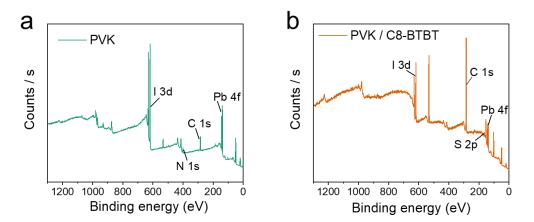


Figure S6. Full XPS spectra of a) perovskite film, b) C8-BTBT prepared on perovskite film.

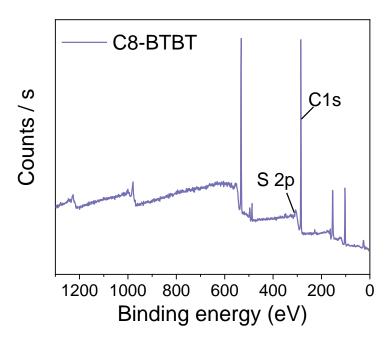


Figure S7. Full XPS spectra of bare C8-BTBT film.

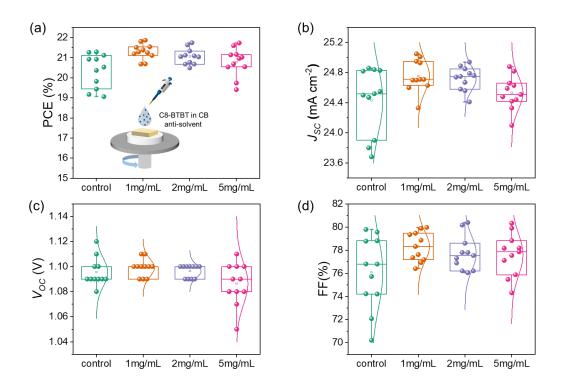


Figure S8. Statistics on photovoltaic parameters of a) PCE, b) J_{SC} , c) V_{OC} and d) FF depending on the various concentration of C8-BTBT anti-solvent modified devices.

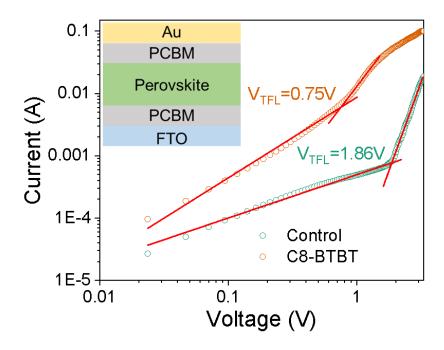


Figure S9. Dark J-V curves of control and C8-BTBT antisolvent modified devices.

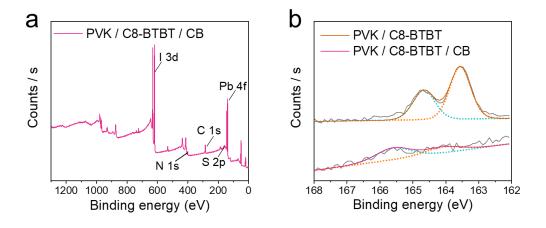


Figure S10. a) Full XPS spectra of C8-BTBT modified perovskite film washed by pure CB solvent, and b) XPS core-level spectra of S 2p in C8-BTBT modified perovskite film with and without CB washing.

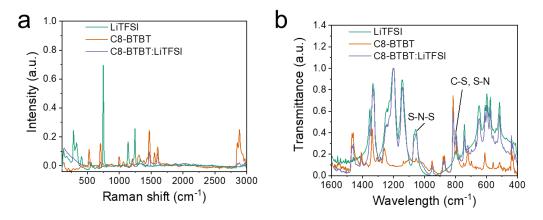


Figure S11. a) Raman Spectra and b) FTIR spectra of the mixture of C8-BTBT and LiTFSI, LiTFSI and C8-BTBT powders, respectively.

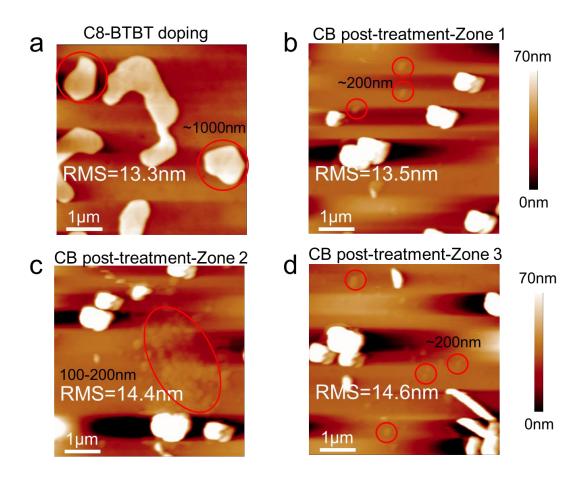


Figure S12. AFM image of a) C8-BTBT doped Spiro-OMeTAD film, b-d) AFM images of C8-BTBT doped Spiro-OMeTAD film in different areas after CB post-treatment.

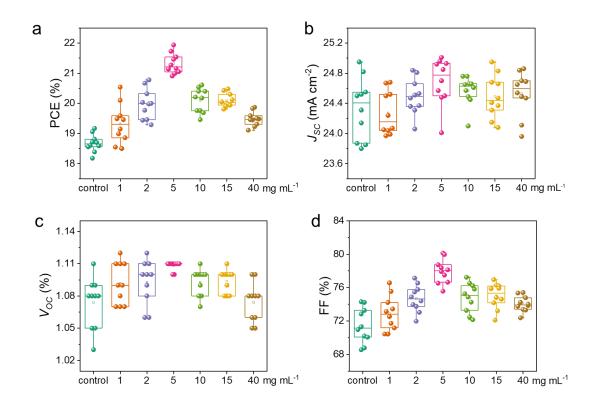


Figure S13. Statistics on photovoltaic parameters of (a) PCE, (b) J_{SC} , (c) V_{OC} , and (d) FF modified with and without various concentrations of C8-BTBT based on 10 devices.

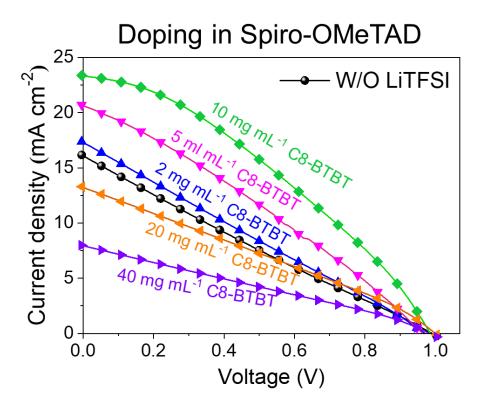


Figure S14. The current density-voltage (*J-V*) curves of the devices with different concentrations of C8-BTBT doped Spiro-OMeTAD (without LiTFSI dopants).

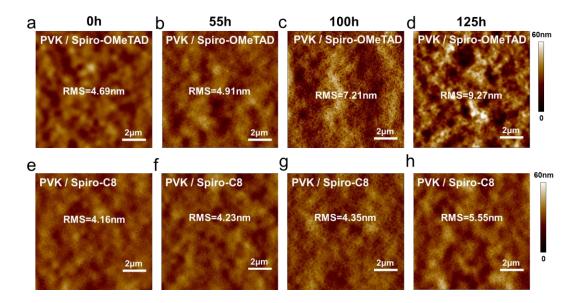


Figure S15. The AFM images of (a-d) Spiro-OMeTAD and (e-h) Spiro-C8 on top of perovskite films at 65°C in different periods.



Figure S16. The water contact angle measurement of Spiro-OMeTAD, Spiro-C8 and C8-BTBT on perovskite films, respectively.

Table S1. Fitted results of TRPL decay curves in Figure 2f.

Films	\mathbf{A}_{1}	$\tau_1(ns)$	A_2	$\tau_2(ns)$	$\tau_{ave.}(ns)$
Glass/perovskite	0.76	12.9	0.24	242.9	209.2
Glass/perovskite/C8-BTBT	0.95	5.3	0.05	353.2	279.2

Table S2. The corresponding photovoltaic parameters (reverse scan) for the control and C8-BTBT-antisolvent modified devices (two-step), measured under AM 1.5 illumination.

Device	J_{SC} (mA cm ⁻²)	<i>V_{OC}</i> (V)	FF (%)	PCE (%)
Control	24.43 ± 0.44	1.09 ± 0.011	76.09 ± 3.15	20.35 ± 0.85
1 mg mL $^{-1}$	24.76 ± 0.21	1.10 ± 0.007	78.31 ± 1.27	21.30 ± 0.38
2 mg mL^{-1}	24.72 ± 0.15	1.09 ± 0.005	77.72 ± 1.49	21.06 ± 0.39
5 mg mL ⁻¹	24.53 ± 0.22	1.09 ± 0.016	77.60 ± 1.83	20.78 ± 0.70

Table S3. Fitted results of TRPL decay curves in Figure 3b for perovskite, perovskite/Spiro-OMeTAD, perovskite/Spiro-C8 films on FTO/TiO₂ surface, respectively.

Films	A_1	τ_1 (ns)	A_2	τ_2 (ns)	$\tau_{ave.}(ns)$
perovskite	0.28	4.4	0.72	122.5	120.9
perovskite/Spiro-OMeTAD	0.70	3.1	0.30	37.6	31.9
perovskite/Spiro-C8	0.80	3.3	0.20	37.8	28.7

Table S4. The average photovoltaic parameters of devices modified with C8-BTBT and without C8-BTBT based on 10 devices for each sample.

	J_{SC}	V_{OC}	FF	PCE	
Device	(mA cm ⁻²)	(V)	(%)	(%)	
Control	24.33 ± 0.41	1.07 ± 0.024	71.46 ± 2.12	18.68 ± 0.29	
1 mg mL^{-1}	24.27 ± 0.29	1.09 ± 0.019	72.93 ± 2.08	19.32 ± 0.65	
2 mg mL^{-1}	24.49 ± 0.24	1.09 ± 0.021	74.70 ± 1.59	19.97 ± 0.51	
5 mg mL^{-1}	24.69 ± 0.31	1.11 ± 0.004	77.95 ± 1.46	21.32 ± 0.34	
10 mg mL^{-1}	24.57 ± 0.19	1.09 ± 0.013	74.82 ± 1.74	20.10 ± 0.40	
15 mg mL ⁻¹	24.49 ± 0.28	1.09 ± 0.011	75.02 ± 1.53	20.10 ± 0.23	
40 mg mL ⁻¹	24.53 ± 0.29	1.07 ± 0.018	74.05 ± 0.95	19.48 ± 0.24	

Table S5. Optimal photovoltaic parameters of the PSCs devices with different concentrations of C8-BTBT doped Spiro-OMeTAD (without LiTFSI dopants).

Device	J_{SC}	V_{OC}	FF	PCE
	(mA cm ⁻²)	(V)	(%)	(%)
W/O LiTFSI	19.47	0.99	19.58	3.78
2 mg mL^{-1}	20.55	0.97	21.00	4.19
5 mg mL ⁻¹	22.41	0.96	27.09	5.85
10 mg mL ⁻¹	23.69	0.99	34.13	7.97
20 mg mL^{-1}	15.45	1.00	23.74	3.67
40 mg mL ⁻¹	9.51	0.98	22.68	2.12

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